



ACCOMPLISHING TRUE KNOWN GOOD DIE VERIFICATION TESTING IN WAFER TEST



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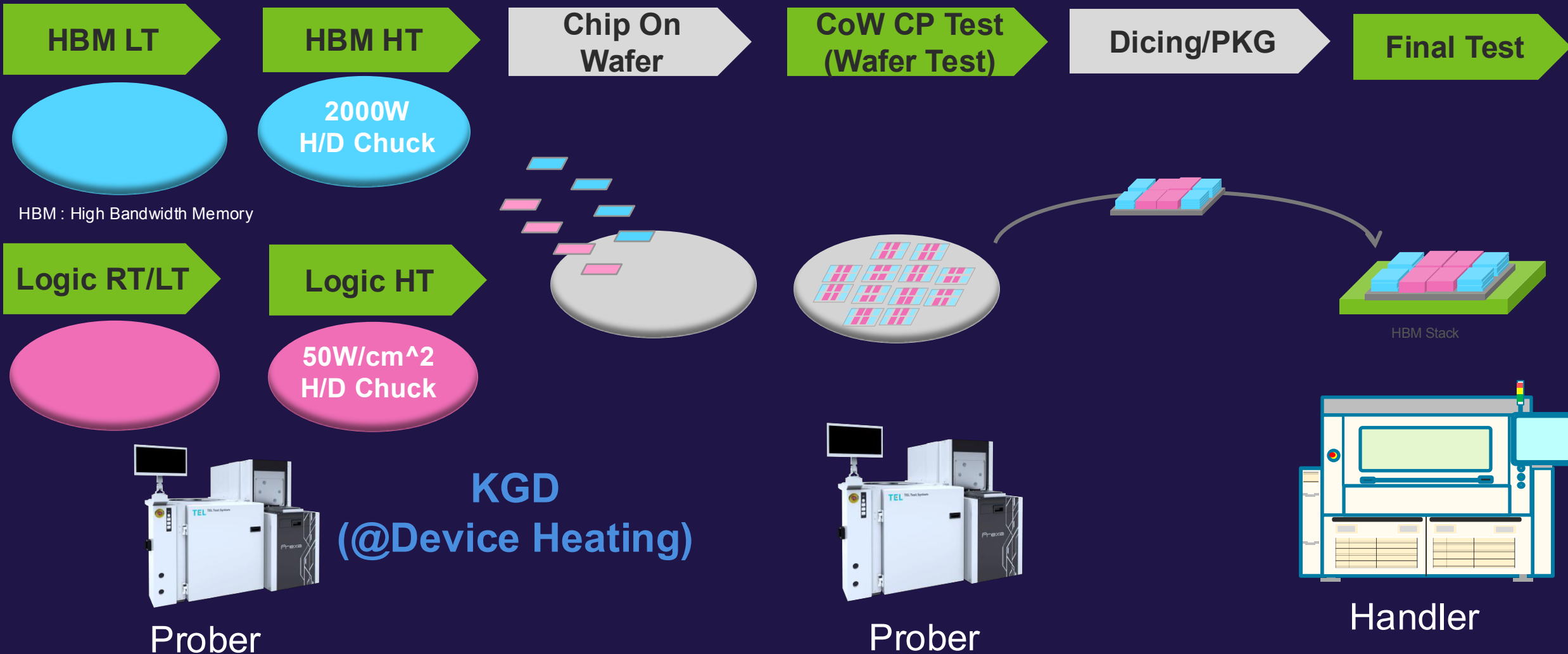


Source: TEL

TEL

Test Trend for Advanced Package

KGD: Known Good Die



Require True Known Good Die verification testing in WAFER TEST for saving cost.
Prober needs active thermal control (ATC) solution to enable KGD in wafer test.

Agenda

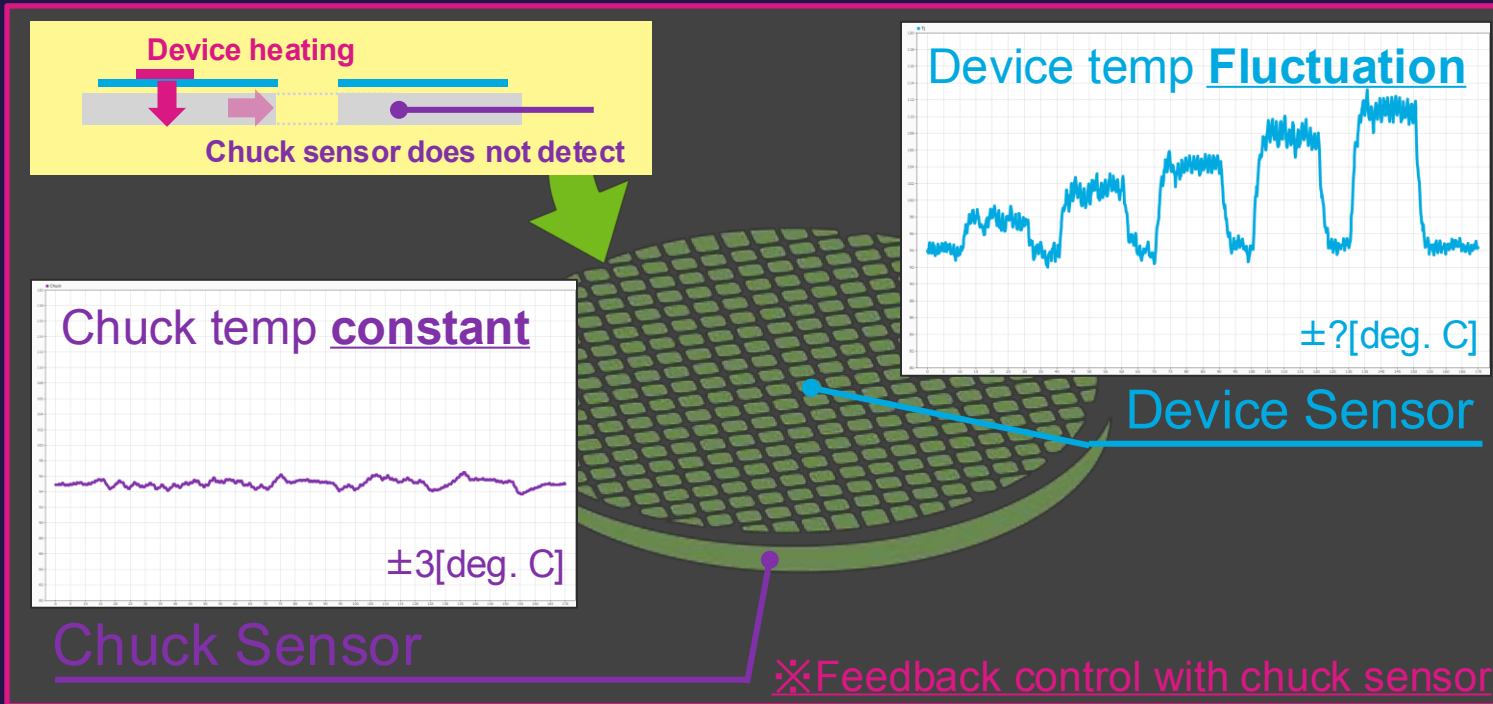
- Background : The challenges of Device Temperature Control $\pm 3^{\circ}\text{C}$ in Prober
- Objectives : Maintain constant device temperature
- New Technology for Active Thermal Control System (ATCS)
 - Item 1 : Tester IF Board
 - Item 2 : Advanced Chuck
 - Item 3 : Model-based controller design
- Key Data
 - Evaluation Fixture and Thermal Control Mode
 - Results of Active Thermal Control and T_j Simulation
- Conclusion

Background :

The challenges of Device Temperature Control $\pm 3^{\circ}\text{C}$ in Prober

- Unable to Device Temperature Control
 - Conventionally maintain constant chuck temperature

Chuck temperature control (conventional)



Future Trends

Active Thermal Control

DTF Control

(Feedback on device temperature)

Advanced Chuck

(50[W/cm²] or more heat absorption)

➔ TEL is up for the challenge



Thermal resistance exists
between the device and the chuck sensor.

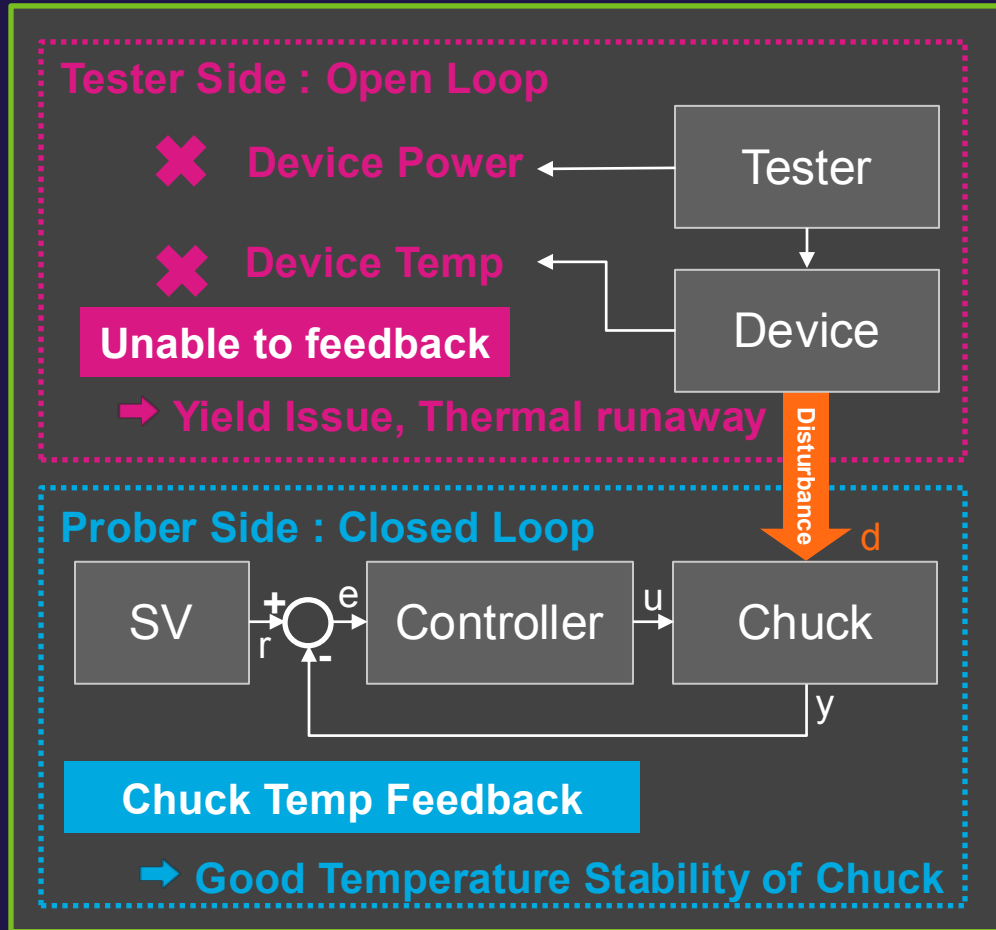
Device temperature control is required

TEL

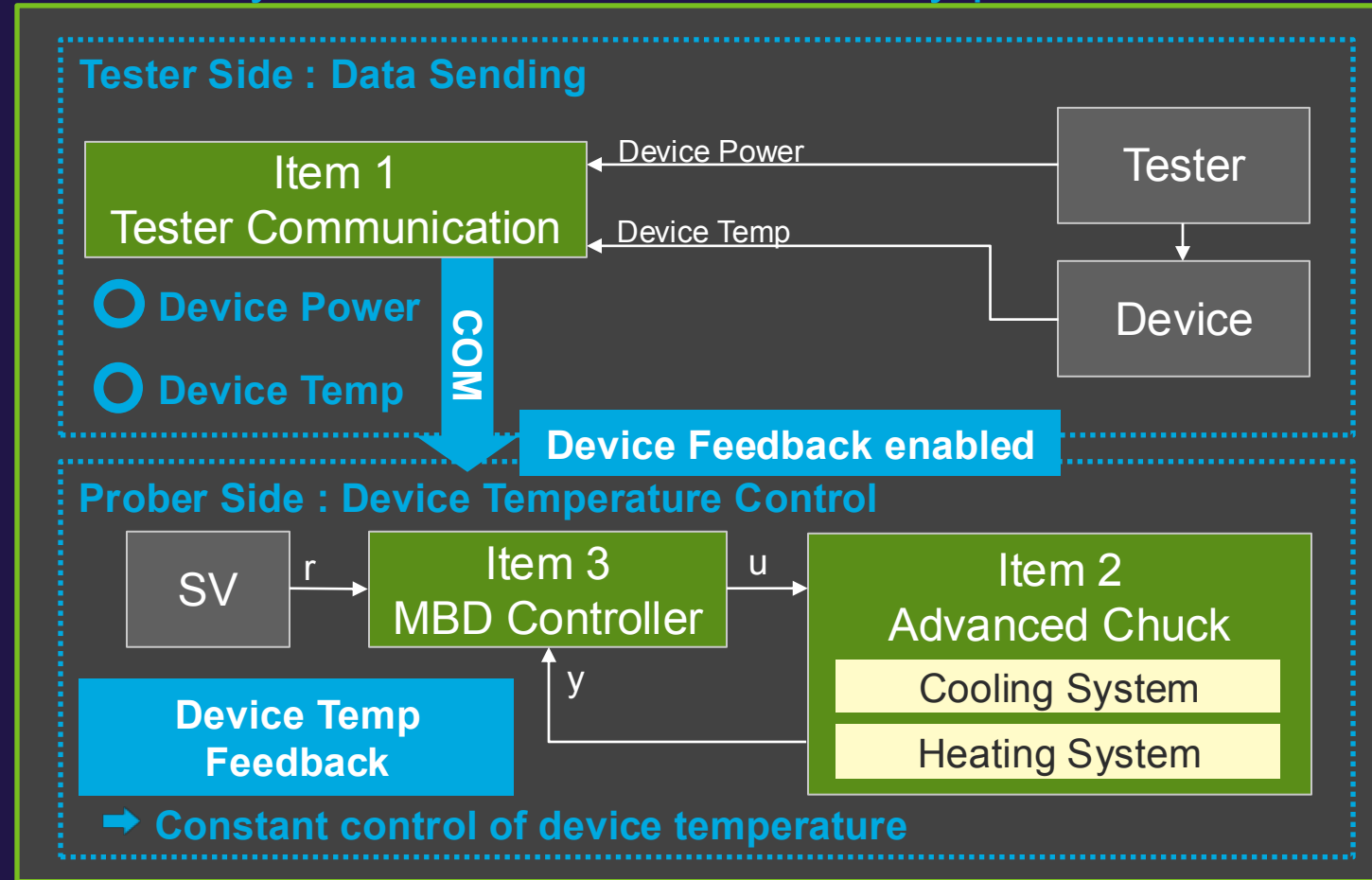
Objectives : Maintain constant device temperature

■ Review of control method

Conventional Control



Control system to be realized and key points

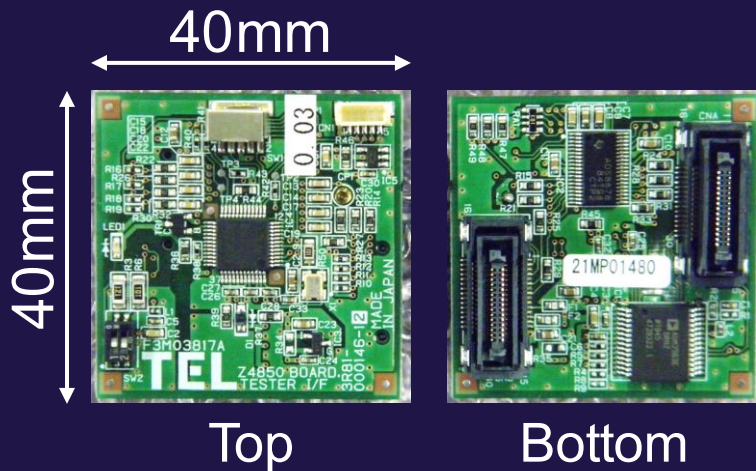


Prober can actively control chuck temperature

New Technology : Tester IF Board

- How to get data from a device

- Tester IF Board



Item	Tester IF Board
Supported Tester	UFP, V93K and more
Tj Signal Type	- Analog Voltage - Digital Packet - Thermal Diode
	Max 32CH
Device Power Feedback	Enable



Tester IF Board sends data from the device to Prober

New Technology : Hardware design of Advanced Chuck

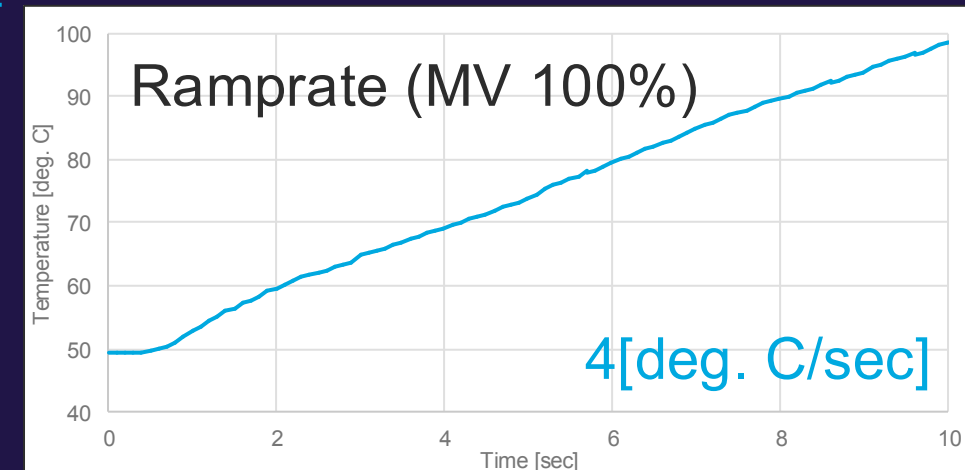
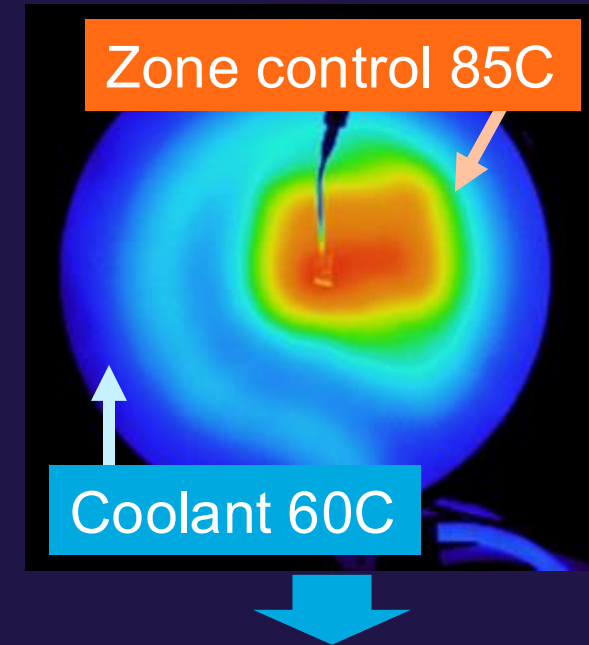
- To control the rapid changes T_j

Multi Chuck Sensor



High Cooling Capacity & High Response Time

- New heater with Zone control
- Chuck top design with small heat capacity
- Coolant with high thermal conductivity
- High Speed Valves

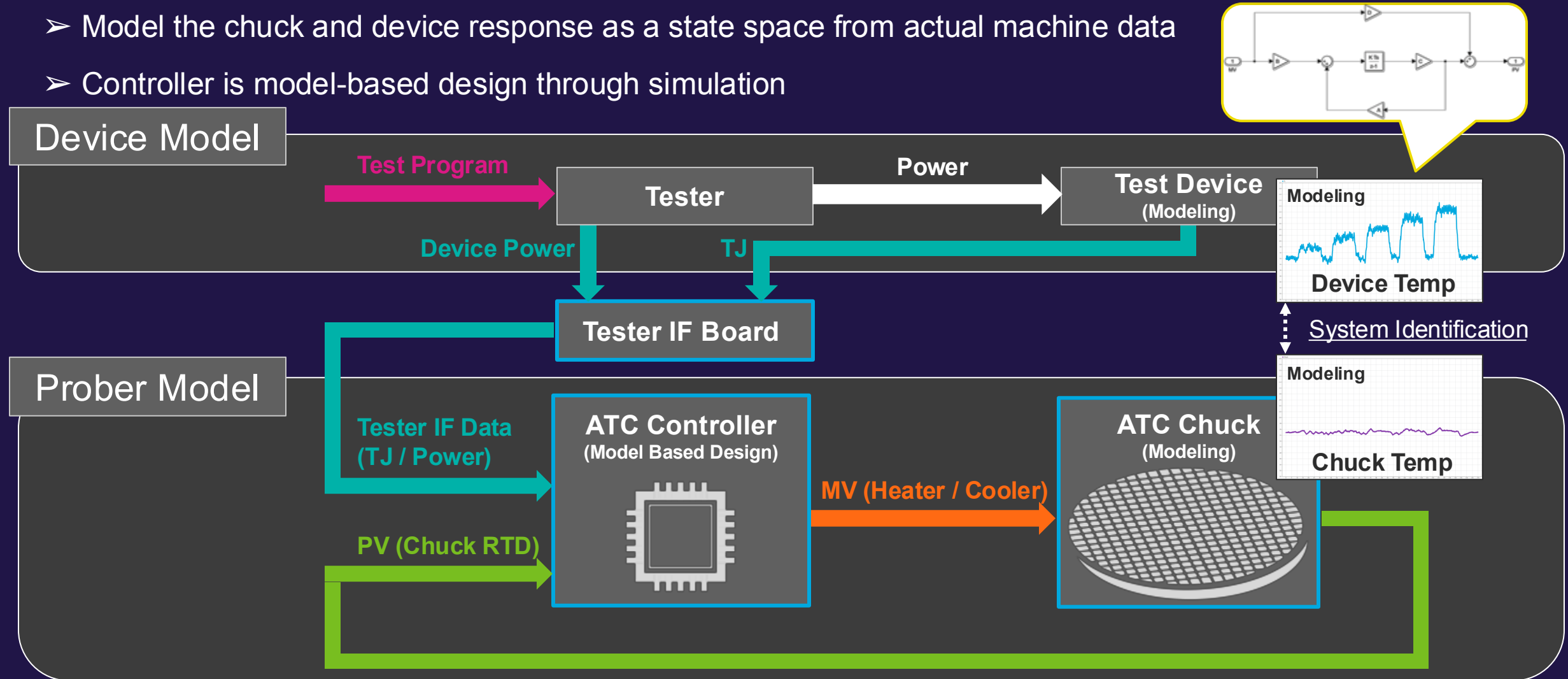


Development items made possible to High Cooling Capacity & High Response Time

New Technology: Model-based controller design

- Overall system for Heat Dissipation Simulation

- Model the chuck and device response as a state space from actual machine data
- Controller is model-based design through simulation

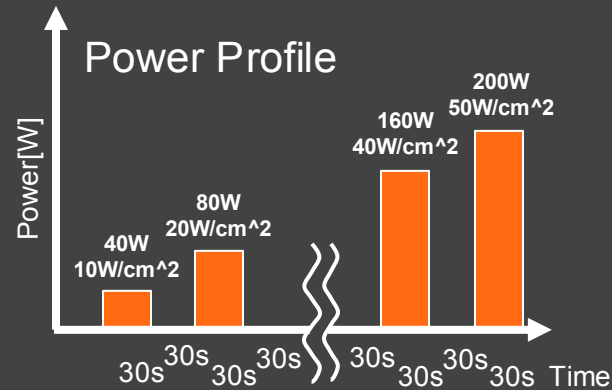
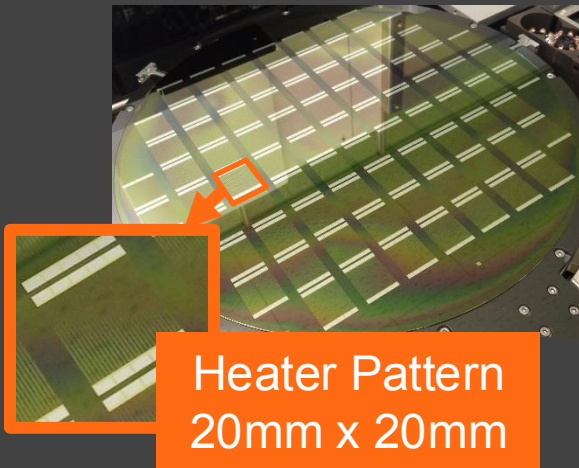


Let's discuss the details in the Key Data section

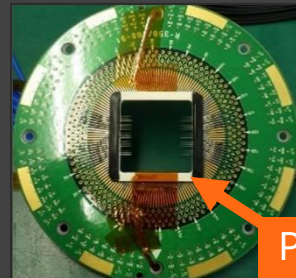
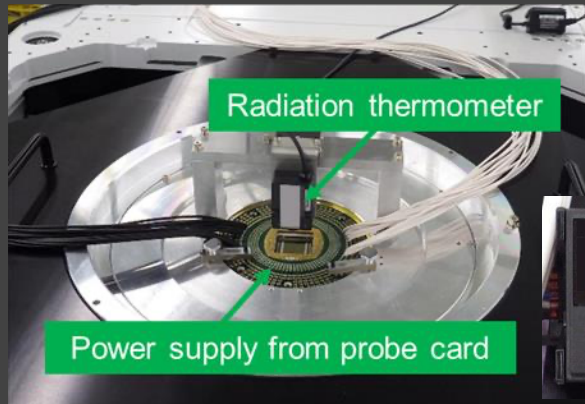
Key Data : Evaluation Fixture and Thermal Control Mode

■ Evaluation Fixture

- Heating Device on wafer



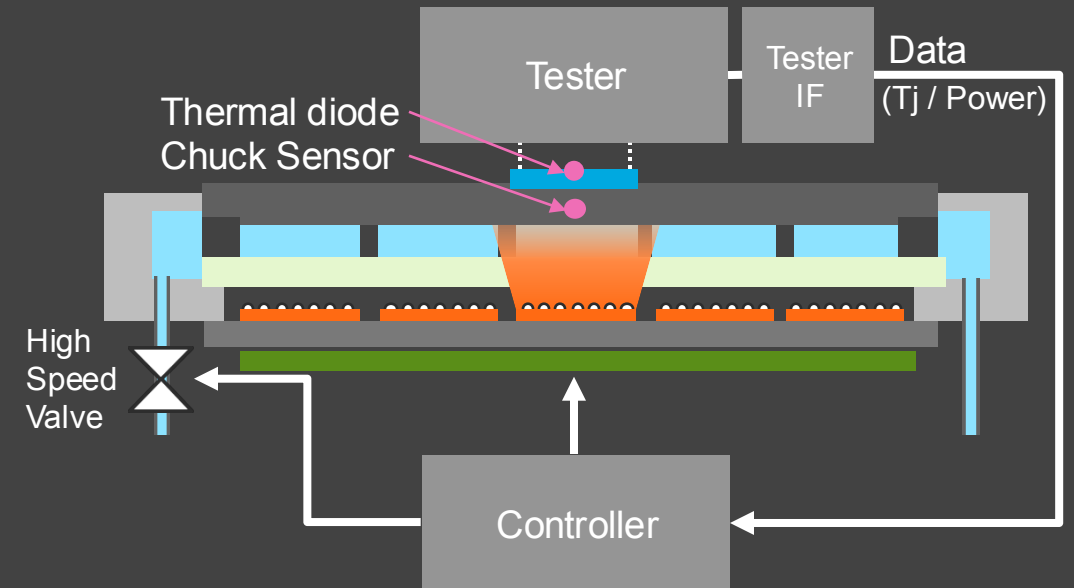
- Measuring Device temp



■ Thermal Control Mode

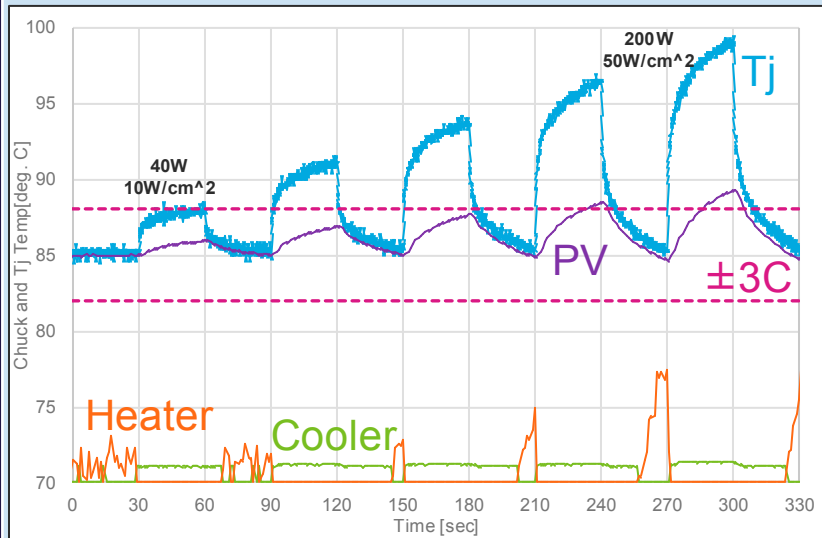
4 modes are available

- HTF (Chuck Temp Feedback)
- DTF (Device Temp Feedback)
- PF (Power Following)
- GPIB Offset



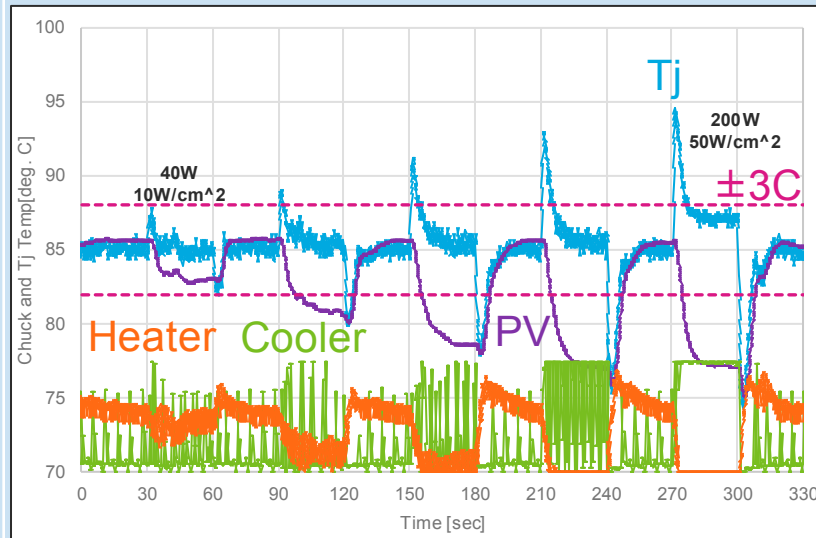
Key Data : Results in each control mode @85C

Conventional Prober Chuck Temperature Feedback



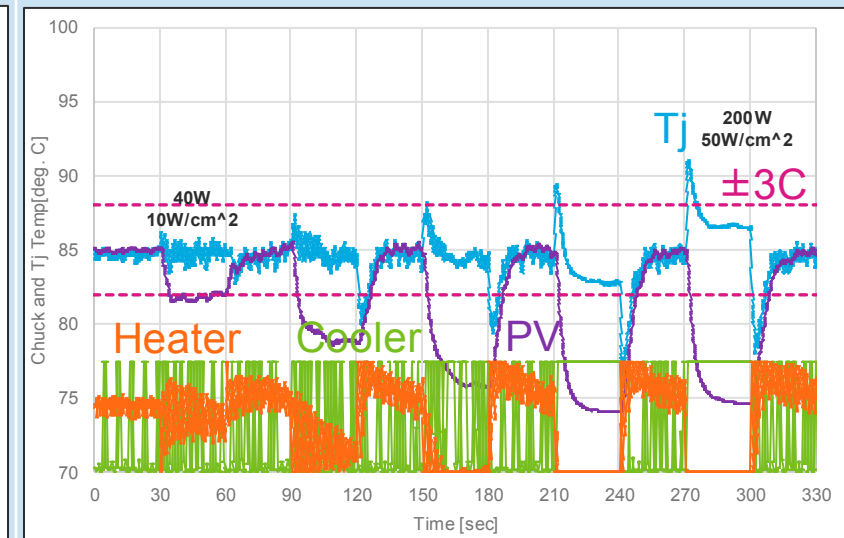
- Prober controls **Chuck PV**
- **Difficult to cool**
high heat generating Device
- Device Power below 40W(10W/cm²)
and within the guard band(±3C)

New Technology (ATCS) DTF Mode (Device Temp Feedback)



- **Chuck PV** changes actively
to keep Device Temp constant
- **Overshoot by time constant**
 $\tau_{Chuck} > \tau_{Wafer}$
- Device Power below 200W(50W/cm²)
and within the guard band(±3C)

New Technology (ATCS) PF Mode (Power Following)

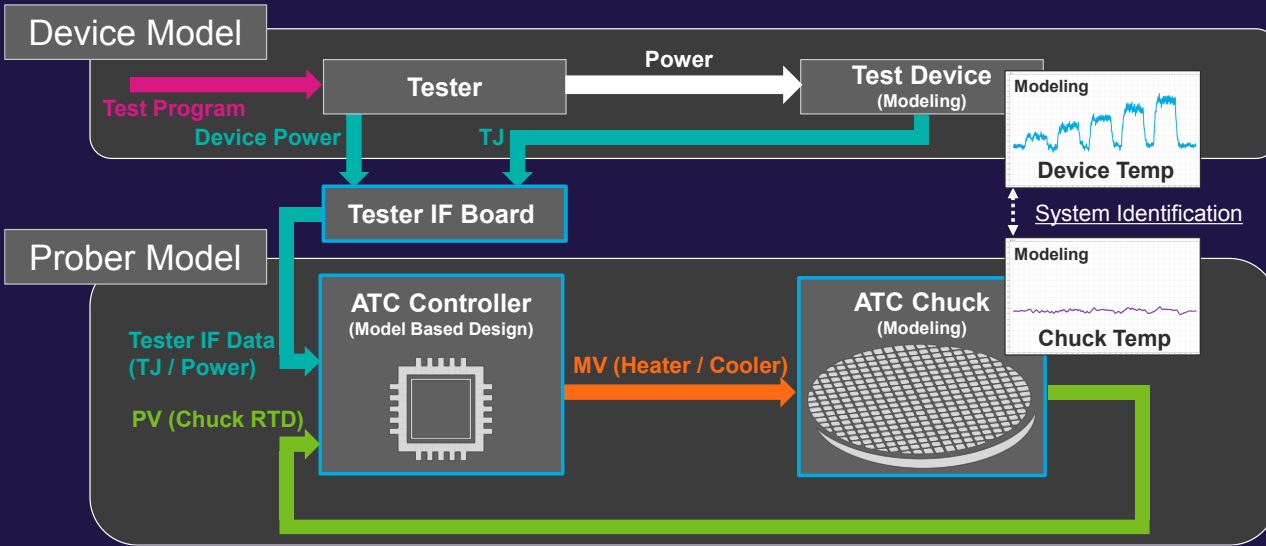


- **Chuck PV** is faster than DTF Mode
- Device Power within the guard band
range is the same as DTF Mode
- Estimates and controls Tj from power
- Overshoot can be suppressed
up to 120W(30W/cm²)

Successful device temperature control by DTF Mode / PF Mode

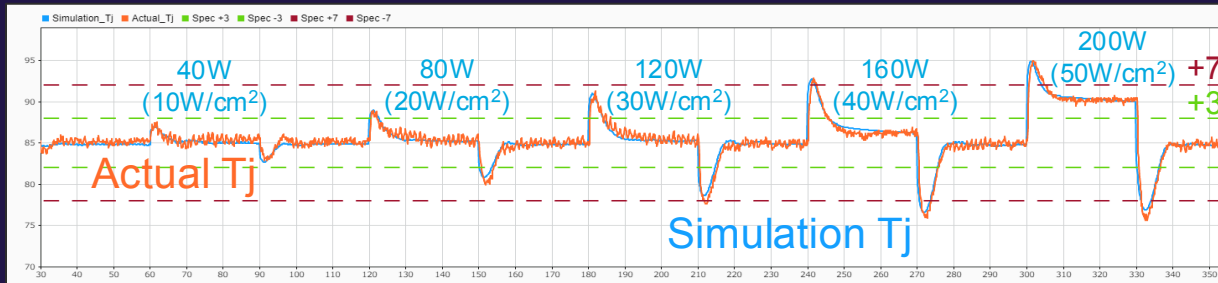
Key Data : Tj Simulation

■ Overall system for Heat Dissipation Simulation



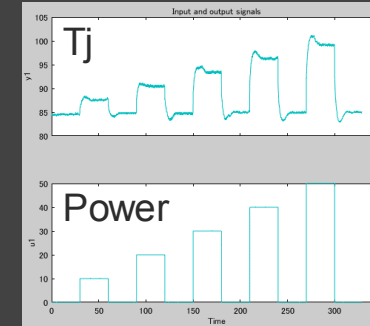
■ Actual vs Simulation

Simulation result was quite much with actual data.

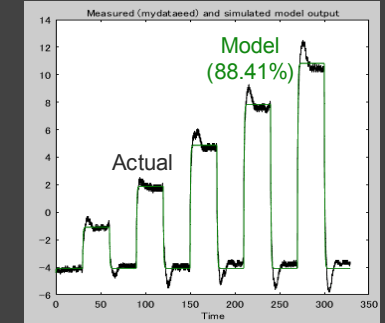


- Creating a device model

- Identify the Tj change relative to test power input.



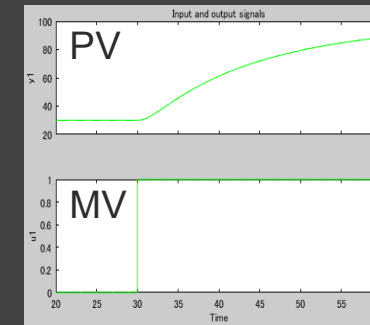
Power/Tj Log



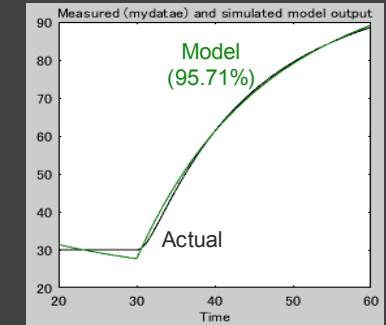
Identification

- Creating a chuck model

- Identify the chuck RTD change relative to heater input.



MV/PV Log



Identification

The Prober was developed on a model basis using a simulator

Conclusion

- New Technology enables Device Temperature Control at Wafer Level, and in evaluations, T_j was maintained within $\pm 3^\circ\text{C}$ at a power of $50\text{W}/\text{cm}^2$
- The following changes were effective for high-heat generating devices
 - Fast response time due to improved thermal capacity of chuck
 - Unique thermal systems and controllers

New Technology enables True KGD verification testing in wafer test , contributing to the future evolution of Logic devices and chiplets

Future Work

- Wide range of temperature
- Increased cooling capacity
- Further Improvement of Response Time

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